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## Fabrication of Direct-Printed OTFT Array Using Flexible h-PDMS Stamp

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Printed organic thin-film transistors (OTFTs) for use as a switching device in an organic light-emitting diode (OLED) were fabricated by microcontact and direct printing at room temperature. The printed OTFT was used in the fabrication of a printed gate with source and drain electrodes (W/L = 500  $\mu$ m/5  $\mu$ m, 500  $\mu$ m/10  $\mu$ m, and 500  $\mu$ m/20  $\mu$ m) printed using a hard poly (dimethylsiloxane) (h-PDMS) stamp and low-viscosity Ag ink, a spin coated parylene-C gate dielectric, and a soluble poly (3-hexylthiophene-2,5-dily) (P3HT) organic semiconductor on flexible, transparent poly(ethylenenaphthalate) (PEN) plastic substrates. The printed OTFT was characterized and the following parameters were obtained: a mobility of 0.06 (±0.02) cm<sup>2</sup>/Vs, an on/off current ratio of 10<sup>3</sup>, and a subthreshold slope of 2.53 V/decade. Also, it was possible to fabricate a printed OTFT with channel lengths down to 5  $\mu$ m, and reduce the fabrication process by 20 steps compared with photolithography.

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